Picosecond Timing Sensor Development Employing MicroPattern (Gaseous or Si) Detector Technology

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representing:

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Abstract

Soon after the development of "reach-through" technology avalanche diodes (i.e. Silicon with internal gain) by McIntyre and collaborators in the '70's-'90s it was shown that these sensors could be used for MIP(minimum-ionizing particle) timing at the level of ≈ 50 -picosecond resolution. While there has been some progress in the related technologies (i.e. SiPM and LGAD) over the past 20 years an alternate route we have explored using Deep Depleted Silicon Structure and "mesh readout" has resulted in sub-20 picosecond resolution in detectors with a useful pixel size (64 mm²). Perhaps more surprising (and a ~ 2 order of magnitude advance in the state of the art for gas detectors) has been the rapid development over the past year of PICOSEC, which is a gas-detector-based timing technology achieving sub-60 picosecond single-photoelectron time resolution and MIP resolution below 25 picoseconds. I will report on progress in 2017- including large area pad arrays, high-rate capability MMegas and radiation-damage studies of HFS as well as the electronics development that has enabled this.